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SPECIFIC WEAK INTERACTIONS RELATED TO GEOMETRICAL SHAPE OF ASSOCIATING THIOLS: THE FACTOR RESPONSIBLE FOR SELECTIVE MOLECULAR RECOGNITION IN THEIR OXIDATION

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In oxidation of a pair of associating thiols (1d and 2) with  $O_2$ , specific weak interactions related to their geometrical shape such as CH···N and CH···SH interactions are suggested to be responsible for selective molecular recognition.

We report here the experimental evidence to suggest that specific weak interactions related to geometrical shape of associating thiols are responsible for selective molecular recognition in their oxidation.

Two types of model systems were used: the associating system (system A) and non-associating system (system N).<sup>1,2</sup> System A consists of a pair of associating  $O_{H}O_{H}$  thiols (1 and 2)<sup>1</sup>, each having the reaction site (SH), the binding site (-CNCN-), and the recognition site ( $C_{6}H_{4}-R^{1}$  or  $R^{2}$ ); this system is further divided into system  $A_{d}$  (1d and 2), system  $A_{i}$  (1i and 2a), and system  $A_{p}$  (1p and 2a). System N consists of a pair of non-associating thiols (3 and 4)<sup>1</sup>.

A 1:1 mixture of 1 and 2 (or of 3 and 4, 0.5 mmol each) was treated with oxygen in the presence of a catalytic amount of  $\text{Et}_3N$  (0.05 mmol) at 35.0 °C in 12.5 ml of 80% (v/v) acetonitrile-20% water to give an unsymmetrical disulfide (6) and

 $HSCH_{2} (CN)_{m} - R^{1} HSCH_{2}CH_{2}(CH_{2}(NC)_{n} - R^{2})$   $HSCH_{2}(R^{1} = N (CH_{3})_{2} HSCH_{2}CH_{2}(NC)_{n} - R^{2}$   $Id = 2, R^{1} = N (CH_{3})_{2} 2b_{k} = 2, R^{2} = (CH_{2})_{j}CH (CH_{3})_{2} 2b_{k} = 2, R^{2} = (CH_{2})_{k}CH_{2}CH_{2}CH_{3}$   $Ip = 2, R^{1} = H 4a_{j} = 1, R^{2} = (CH_{2})_{j}CH (CH_{3})_{2} 4b_{k} = 1, R^{2} = (CH_{2})_{j}CH (CH_{3})_{2}$ 

 $HS-D + HS-A \xrightarrow{O_2} S-D + S-D + S-A \\ \downarrow & \downarrow & \downarrow \\ S-D & S-A & S-A \\ 1 \text{ or } 2 \text{ or } 5 & 6 & 7 \\ 3 & 4 & & & & & \\ \end{bmatrix}$ 

two symmetrical ones (5 and 7). The selectivity (<u>R</u>) in this oxidation is represented by the ratio of the yield<sup>1</sup> of 6 to that of 5 (<u>R</u> = 6/5).<sup>3</sup>

Previously we have reported that the selectivity in oxidation of system  $A_d$  depends sharply on the structure of  $R^2$ :<sup>3</sup> (i) in the case of 1d and 2a maximal selectivity (<u>R</u>=21) occurs at 2a<sub>2</sub> (j=2), <u>R</u> being 0.84, 1.2, 21, 13, and 11 for j=0, 1, 2, 3, and 4, respectively, and (ii) with 1d and 2b alternation in the selectivity is clearly observed, <u>R</u> being 4.5, 0.28, 0.53, 0.29, and 0.40 for k=0, 1, 2, 3, and 4, respectively. In order to elucidate a factor governing these radical changes in <u>R</u>, some attempts were made.<sup>4</sup>

Oxidation of system N clarified that with 3 and 4a (j=0 to 3) the selectivity showed almost no changes ( $\underline{R}$ =1.8 to 1.9) and that with 3 and 4b (k=0 to 3)  $\underline{R}$  decreased progressively from 2.0 to 0.50 with "k", thus demonstrating that intermolecular association between a pair of thiols is first required for the sharp response of  $\underline{R}$  to the structure of  $\underline{R}^2$  — selective molecular recognition. Further, the rate of the oxidation remained almost unaltered with  $\underline{R}^2$  under conditions similar to those described above (at 0.010 M): (i) in system  $\underline{A}_d$  the time required for 50% oxidation ( $\tau_{0.5}$ ) was 76±6, 62±5, and 64±5 min for j=0, 2, and 4, respectively, and (ii) in system N the  $\tau_{0.5}$  value was 28±2 and 27±2 min for j=0 and 2, respectively. These results suggest that the dependence of chemical reactivity difference between 1d and 2 on the structure of  $\underline{R}^2$  is not related to the sharp structure dependence of  $\underline{R}$  for system  $\underline{A}_d$ .

Our previous work has shown that tetramers (8-12) composed of 1d and 2 (Figure 1) are intermediates of their oxidation.<sup>6</sup> Each of these tetramers would give the corresponding disulfide(s) selectively when treated with oxygen —— (i) hetero-tetramer 8 gives 5, 6, or 7, (ii) heterotetramers 9 and 10 exclusively give 6, and (iii) homotetramers 11 and 12 exclusively give 5 and 7, respectively. This



Figure 1. Schematic drawings of the conformations of tetramers (8-12) formed by dimerization of dimers. ....., Hydrogen bond responsible for stabilization of dimers; -----, non-covalent interactions responsible for stabilization of tetramers.



Figure 2. Dependence of  $\underline{f}$  and melting point for 2a or 13a on the structure of  $R^2$  or  $R^3$ .  $\bigcirc$ ,  $\underline{f}$  of 2a;  $\bigcirc$ ,  $\underline{f}$  of 13a;  $\triangle$ , melting point of 2a;  $\triangle$ , melting point of 13a.

consideration together with the results mentioned above leads us to assume that selective molecular recognition would be ascribed to the dependence of relative concentration of the tetramers on the structure of  $R^2$ . This assumption is supported by NMR results that the NH proton of 2 participating in intermolecular hydrogen bonding underwent a considerably larger downfield shift<sup>7</sup> (0.2 ppm) for a 1:1 mixture of 1d and 2a<sub>2</sub> than for a 1:1 mixture of 1d and 2b<sub>2</sub> in CDCl<sub>3</sub> at 0.01 M and 32 °C.

Since the solvent used in this oxidation was aqueous acetonitrile, hydrophobic interaction may be associated with the control of molecular recognition. However, the following data cannot be explained by hydrophobic contribution to the selectivity for system  $A_d$ : (i) plots of <u>R</u> in oxidation of 1d and 2a<sub>2</sub> against the volume percent of water in acetonitrile-water mixtures showed a maximum at 20% of water, but not a progressive increase with increasing volume percent of water,  $^{3,8}$  and (ii) the increasing (or decreasing) order of the  $\pi$  value<sup>9</sup> of an alkyl group employed as R<sup>2</sup> in 2 is quite different from the increasing (or decreasing) order of <u>R</u> in oxidation of system  $A_d$  for the corresponding alkyl group. Therefore, selective molecular recognition in oxidation of system  $A_d$  would best be attributed to specific weak interactions related to geometrical shape of the recognition sites and the reaction sites in tetramers. Possible candidates for weak interactions are CH···N<sup>10</sup>, CH···SH, SH···SH<sup>11</sup>, and SH···N<sup>11</sup> interactions, <sup>12</sup> the first two interactions  $^{13}$  mainly contributing to the selectivity <u>R</u>.

Thiol 2t  $(n = 2, R^2 = p-CH_3C_6H_4)$  formed a solid 1:1 complex<sup>6</sup> with 1d, but not with 1p, suggesting the contribution of CH···N interaction between an alkyl group in R<sup>2</sup> and the amino group in R<sup>1</sup> to the stabilization of the solid complex. The contribution of CH···N interaction to selective molecular recognition is suggested by the finding that the structure dependence of <u>R</u> was less sharp for systems A<sub>i</sub> and A<sub>p</sub> than for system A<sub>d</sub> — (i) with system A<sub>i</sub> the <u>R</u> value was 5 both for j = 0 and 2, and (ii) with system A<sub>p</sub> the <u>R</u> value was 2.6 and 6.2 for j = 0 and 2, respec-

tively. Moreover, <sup>1</sup>H NMR studies of unsymmetrical disulfides derived from 1d and  $2a_2$  [6d (j=2)], 1d and  $2b_2$  [6d (k=2)], and 1p and  $2a_2$  [6p (j=2)] in CDCl<sub>3</sub> at 0.005 M and 34 °C revealed that the NH<sup> $\alpha$ </sup> proton underwent a downfield shift of 0.19 or 0.18 ppm in going from 6p (j=2) to 6d (j=2) or from 6d (k=2) to 6d (j=2), respectively; these results indicate that CH···N interaction is



attractive and specific, and thus makes the NH<sup>α</sup>···O hydrogen bonding stronger. Figure 2 shows that degree of association<sup>2</sup> (<u>f</u>) in benzene at 0.04 M is larger for 2a than for its derivative, CH<sub>3</sub>CH<sub>2</sub>CH<sub>2</sub>CH<sub>2</sub>NCNC-R<sup>3</sup> [13a; R<sup>3</sup> = (CH<sub>2</sub>)<sub>j</sub>CH(CH<sub>3</sub>)<sub>2</sub>], except in the case of R<sup>2</sup> = R<sup>3</sup> = isoC<sub>4</sub>H<sub>9</sub> and that the melting point<sup>14</sup> of 2a is higher than that of 13a by 20 to 40 °C. Higher <u>f</u> and melting point of 2a would be viewed as being due to attractive CH···SH interaction between an alkyl and the SH groups.

From all of the data presented here, it may be concluded that specific weak interactions related to geometrical shape of the recognition sites are responsible for selective molecular recognition in oxidation of system  $A_d$ .

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discussions, Mr. Yuji Kaneko for valuable assistance, and the Ministry of Education, Japan, for financial support.

## References and Notes

- The preparation of thiols 1-4 and the determination of the yields of 5 and 6 1) were made as described before (T. Endo, Y. Takeda, H. Kamada, S. Kayama, and H. Tasai, Chem. Lett., 1980, 417). All new compounds had satisfactory spectral data.
- The degree of association (f), obtained by dividing the stoichiometric mole fraction of the solute by the effective mole fraction of the solute, was 2) measured at 36.0 °C in benzene. The f value at 0.01 M was less than 1.05 for 3 and 4, and ranged from 1.3 to 1.5 for 1 and 2 except that f of 1p was 1.30 at 0.02 M.
- 3) T. Endo, A. Kuwahara, H. Tasai, T. Murata, M. Hashimoto, and T. Ishigami, Nature, <u>268</u>, 74 (1977).
- It has been confirmed with oxidation of system  $A_d$  that (i) the product ratio R 4) is kinetically controlled and (ii) the selectivity is not controlled by solubility differences between thiols (1d and 2) and between disulfides (5-7).<sup>3</sup>
- 5)
- The time required for 10% oxidation of 2a alone was all <u>ca</u>. 10 h. T. Endo, Y. Takeda, T. Orii, Y. Kaneko, and M. Kondo, Chem. Lett., <u>1979</u>, 1455. A downfield shift of the NH proton implies that NH···O hydrogen bonding 6) 7)
- becomes stronger. 8) The dielectric constant and surface tension of acetonitrile-water mixtures are
- known to increase progressively with increasing volume percent of water. The  $\pi$  value (an excellent parameter of hydrophobicity) is reported to increase 9) in the order  $isoC_{3}H_{7} < n-C_{3}H_{7} < isoC_{4}H_{9} < n-C_{5}H_{11} < n-C_{6}H_{13} < n-C_{7}H_{15}$  (C. Hansch, A. R. Steward, J. Iwasa, and E. W. Deutsch, Mol. Pharmacol., 1, 205 (1965)).
- 10) The presence of this interaction was suggested by the fact that ab initio SCF MO calculations showed the total interaction energy for a complex of  $CH_4$  with  $NH_3$  to be -1.1 kcal/mol (K. Morokuma, Acc. Chem. Res., 10, 294 (1977)).
- The SH...SH and SH...N interactions are regarded as weak hydrogen bonding (N. 11) L. Allinger, M. P. Cava, D. C. De Jongh, C. R. Johnson, N. A. Lebel, and C. L. Stevens, "Organic Chemistry", Worth, New York, 1971), and appear to be relatively unimportant as weak interactions affecting changes in  $\underline{R}$  with  $\underline{R}^2$ .
- The CH···CH interaction of an alkyl group in  $R^2$  with itself (or of an alkyl group in  $R^2$  with the methyl group in  $N(CH_3)_2$ ) would also affect the selectivity, as suggested by the finding that the melting point of 13a showed 12) a small maximum at  $\hat{R}^3 = isoC_4 H_9$  (Figure 2). This interaction would appear to play a major role in the predominance of a rotamer in 1,3,5-trineopentylbenzene with all three neopentyl groups on the same side of the benzene ring in CDCl<sub>3</sub> (R. E. Carter and P. Stilbs, J. Am. Chem. Soc., <u>98</u>, 7515 (1976)).
- 13) These two interactions are assumed to possess the following features: (i) they have energies smaller than that for hydrogen bond, (ii) they are interactions between groups, between a group and an atom, or between atoms, which reflect the nature of the interacting groups or atoms, and (iii) they have high specificity (e.g., as to directionality); they may be generally involved in van der Waals interaction.
- 14) Considering that intermolecularly hydrogen-bonded materials have higher melting points than the corresponding similar sized compounds (G. C. Pimentel and A. L. McClellan, "The Hydrogen Bond", Freeman, San Francisco, 1960, p 35), it seems reasonable to consider that melting points would also be raised by specific weak interactions discussed here. Since homodimers in solution adopt the head-to-tail conformations, also in the solid state 2 would adopt the head-to-tail conformation. Recently, a relationship was found to exist between the selectivity  $\underline{R}$  in oxidation of system  $\underline{A}_{\underline{d}}$  and the melting point of 2 (T. Endo, Y. Takeda, T. Orii, A. Kuwahara, M. Ohta, M. Sakai, R. Okada, and M. Hashimoto, Bull. Chem. Soc. Jpn., in press). This correlation may be explained by assuming that specific weak interactions between 1d and 2 are similar, in the dependence on  $R^2$ , to those of 2 with itself.

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